

08/28/01

Class	Subclass
ISSUE CLASSIFICATION	

PATENT NUMBER

## U.S. UTILITY Patent Application

U.S. OFFICE Patent Application	
O.I.P.E.	PATENT DATE
SCANNED <i>104</i> Q.A. <i>AA</i>	

APPLICATION NO. 09/939773	CONT/PRIOR F	CLASS 438	SUBCLASS	ART UNIT 2812	EXAMINER Coleman
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TITLE	APPLICANTS
1. <i>General</i>	
2. <i>Specific</i>	
3. <i>Other</i>	

Koji Kibuchi

Manufacturing method of a phase shift mask, method of forming a resist pattern and manufacturing method of a semiconductor device

PTO-2040  
12/99

ISSUING CLASSIFICATION											
ORIGINAL				CROSS REFERENCE(S)							
CLASS		SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)						

☐ Continued on Issue Slip inside File Jacket.

<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	<b>DRAWINGS</b> Sheets Drwg.      Figs. Drwg.      Print Fig.		<b>CLAIMS ALLOWED</b>	
			Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.  <input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____  <input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Assistant Examiner) _____ (Date)  _____ (Primary Examiner) _____ (Date)  _____ (Legal Instruments Examiner) _____ (Date)		<b>NOTICE OF ALLOWANCE MAILED</b>	
			<b>ISSUE FEE</b> Amount Due      Date Paid	

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